

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	5773	430/270.1	US-PGPUB; USPAT	OR	OFF	2007/05/23 07:55
L2	1280	430/271.1	US-PGPUB; USPAT	OR	OFF	2007/05/23 07:55
L3	240	430/275.1	US-PGPUB; USPAT	OR	OFF	2007/05/23 13:03
L4	113	430/276.1	US-PGPUB; USPAT	OR	OFF	2007/05/23 09:58
L5	68	430/277.1	US-PGPUB; USPAT	OR	OFF	2007/05/23 09:02
L6	10	430/279.1	US-PGPUB; USPAT	OR	OFF	2007/05/23 09:02
L7	3	09/864384	US-PGPUB; USPAT	OR	OFF	2007/05/23 10:00
L8	3	"6582884"	US-PGPUB; USPAT; DERWENT	OR	OFF	2007/05/23 12:40
L9	5	"7005232"	US-PGPUB; USPAT; DERWENT	OR	OFF	2007/05/23 12:41
L10	2	"7005232"	DERWENT	OR	OFF	2007/05/23 12:41
L11	1	2005-088449.NRAN.	DERWENT	ADJ	ON	2007/05/23 12:43
L12	0	2005/0064322	DERWENT	ADJ	ON	2007/05/23 12:58
L13	1	"7175966"	DERWENT	ADJ	ON	2007/05/23 12:58
L14	1	2005-293832.NRAN.	DERWENT	ADJ	ON	2007/05/23 12:59
L15	7511	substrate same multilayer same metal	US-PGPUB; USPAT	OR	OFF	2007/05/23 13:07
L16	1751	photoresist and I15	US-PGPUB; USPAT	OR	OFF	2007/05/23 13:04
L17	274	substrate same multilayer same metal same photoresist	US-PGPUB; USPAT	OR	OFF	2007/05/23 14:06
L18	0	wo-199858373-\$.did.	US-PGPUB; USPAT	OR	OFF	2007/05/23 14:07
L19	0	wo-1998058373-\$.did.	US-PGPUB; USPAT	OR	OFF	2007/05/23 14:07
L20	0	wo-19980058373-\$.did.	US-PGPUB; USPAT	OR	OFF	2007/05/23 14:07
L21	0	wo-1998/58373-\$.did.	US-PGPUB; USPAT	OR	OFF	2007/05/23 14:08
L22	0	wo-199858373-\$.did.	US-PGPUB; USPAT; DERWENT	OR	OFF	2007/05/23 14:08
L23	0	wo-1998058373-\$.did.	US-PGPUB; USPAT; DERWENT	OR	OFF	2007/05/23 14:08
L24	3	"6582884"	US-PGPUB; USPAT; DERWENT	OR	OFF	2007/05/23 14:08
S1	1	((MASAHIKO) near2 (KATSUMURA)).INV.	US-PGPUB; USPAT	ADJ	ON	2007/05/21 13:28
S2	0	((MASAHIKO) near2 (KATSUMURA)).INV.	EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:28

EAST Search History

S3	286001	substrate and (resist or photoresist)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:29
S5	2687823	(Sc or Ti or V or Cr or Mn or Fe or Co or Ni or Cu or Zn or Ga or Ge or As or Se or Br or Kr)same (layer or coating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:56
S6	1901502	(Sr or Y or Zr or Nb or Mo or Te or Ru or Rh or Pd or Ag or Cd or In or Sn or Sb or Te or I or Xe or La or Hf or Bi)same (layer or coating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:45
S7	222986	S3 and (S5 or S6)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:46
S8	57926	substrate same photoresist same (S5 or S6)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:46
S9	783463	(Sr or Y or Zr or Nb or Mo or Te or Ru or Rh or Pd or Ag or Cd or Sn or Sb or Te or I or Xe or La or Hf or Bi)same (layer or coating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:45
S10	50799	substrate same photoresist same (S5 or S9)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:48
S11	5839	"electron beam" and S10	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:50
S12	16876	"electron beam" and substrate and photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 14:48
S13	41489	"electron beam" same substrate	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:53
S14	73336	substrate same photoresist same (layer or coating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:53
S15	4906	S13 and S14	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 13:55
S16	2687823	("Sc" or "Ti" or "V" or "Cr" or "Mn" or "Fe" or "Co" or "Ni" or "Cu" or "Zn" or "Ga" or "Ge" or "As" or "Se" or "Br" or "Kr")same (layer or coating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 14:45
S17	0	"electron beam" same "record\$3" same substrate	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 14:49
S18	208	substrate same "bottom antireflective" same (resist or photoresist)	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2007/05/21 15:26

EAST Search History

S19	17724793	Sc Ti V Cr Mn Fe Co Ni Cu Zn Ga Ge Se Br Kr Sr Y Zr Nb Mo Tc Ru Rh Pd Ag Cd Sn Sb Indium Te I Xe La	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2007/05/21 15:11
S20	7032430	Ta W Re Os Ir Pt Au Hf Hg T Pb Bi	US-PGPUB; USPAT	OR	ON	2007/05/21 15:10
S21	17724793	Sc Ti V Cr Mn Fe Co Ni Cu Zn Ga Ge Se Br Kr Sr Y Zr Nb Mo Tc Ru Rh Pd Ag Cd Sn Sb Indium Te I Xe La	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2007/05/21 15:11
S22	59253	substrate same (photoresist or resist) same (S20 or S21)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2007/05/21 15:27
S23	1	"7175966"	DERWENT	ADJ	ON	2007/05/21 15:26
S24	1	2005-293832.NRAN.	DERWENT	ADJ	ON	2007/05/21 15:26
S25	78651	substrate and(photoresist or resist) and ((Au or gold or Ta or W or Re or Os or Ir or Pt) same layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2007/05/21 15:30
S26	64199	substrate and(photoresist or resist) and ((Au or gold or Ta or W or Re or Os or Ir or Pt) same layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/21 15:34
S27	8145	substrate same(photoresist or resist) same ((Au or gold or Ta or Re or Os or Ir or Pt) same layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 07:21
S28	24	substrate same(photoresist or resist) same "inorganic dielectric layer"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/21 16:02
S29	1401	substrate same(photoresist or resist) same ((Au or gold or Ta or Re or Os or Ir or Pt) same layer) and "electron beam"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 08:44
S30	636	substrate same(photoresist or resist) same ((Au and Cr) same layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 09:04
S31	821	substrate same "scattering layer"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 09:28
S32	97	(substrate same "scattering layer") and "electron beam"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 09:56
S33	142173	substrate same layer same (Sc or Ti or V or Cr or Mn or Fe or Co or Ni or Cu or Zn or Ga or Ge or Se or Br or Kr)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:32
S34	419141	substrate same layer same (Sr or Y or Zr or Nb or Mo or Tc or Ru or Rh or Pd or Ag or Cd or In or Sn or Sb or Te)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:34
S35	153704	substrate same layer same (I or Xe or La or Hf or Ta or W or Re or Os or Ir or Pt or Au or Hg or T or Pb or Bi)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:36

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S36	32310	photoresist same (S33 or S34 or S35)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 10:48
S37	110386	substrate same layer same (Sr or Y or Zr or Nb or Mo or Tc or Ru or Rh or Pd or Ag or Cd or Sn or Sb or Te)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 10:48
S38	14052	photoresist same (S33 or S37 or S35)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 10:51
S39	1988	photoresist same (S33 or S37 or S35) and "electron beam"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 10:52
S40	168700	substrate with(Sc or Ti or V or Cr or Mn or Fe or Co or Ni or Cu or Zn or Ga or Ge or Se or Br or Kr)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:45
S41	136243	substrate with (Sr or Y or Zr or Nb or Mo or Tc or Ru or Rh or Pd or Ag or Cd or Sn or Sb or Te)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:45
S42	219286	substrate with (I or Xe or La or Hf or Ta or W or Re or Os or Ir or Pt or Au or Hg or T or Pb or Bi)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:46
S43	11417	photoresist same (S41 or S42 or S40)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:37
S44	7348	substrate adj(Sc or Ti or V or Cr or Mn or Fe or Co or Ni or Cu or Zn or Ga or Ge or Se or Br or Kr)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:45
S45	3383	substrate adj(Sr or Y or Zr or Nb or Mo or Tc or Ru or Rh or Pd or Ag or Cd or Sn or Sb or Te)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:46
S46	18729	substrate adj (I or Xe or La or Hf or Ta or W or Re or Os or Ir or Pt or Au or Hg or T or Pb or Bi)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 11:46
S47	621	photoresist same (S44 or S45 or S46)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 12:24
S48	202	"GaAs substrate" same "GaAs layer" same photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2007/05/22 12:24